

Radiation tolerance of opto-electronics and Ge-doped MM fiber

- **850 nm MultiMode technology**
speed to 25 Gbps/ch
fabrication to miniature Chip-on-Board
- **Opto-electronics NIEL/TID radhard**
- **Ge-dope MM fiber TID**
RIA (Radiation Induced Attenuation)

suen@sinica.edu.tw

侯書雲 Suen Hou

2024.10.26 10:20

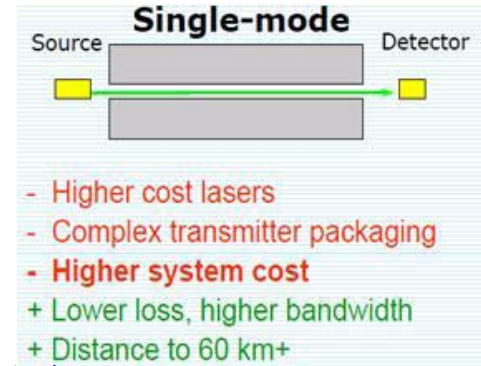
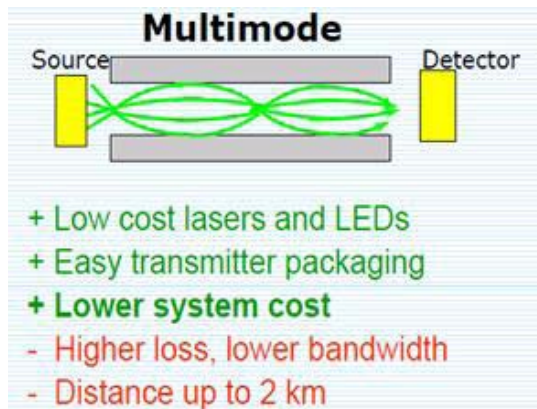


Fiber optical loss

Silica glass fiber:

Low-mass, high bandwidth, little loss over long distance

- Absorption Scattering losses (Rayleigh, Raman...)
- Bending losses (micro bending)

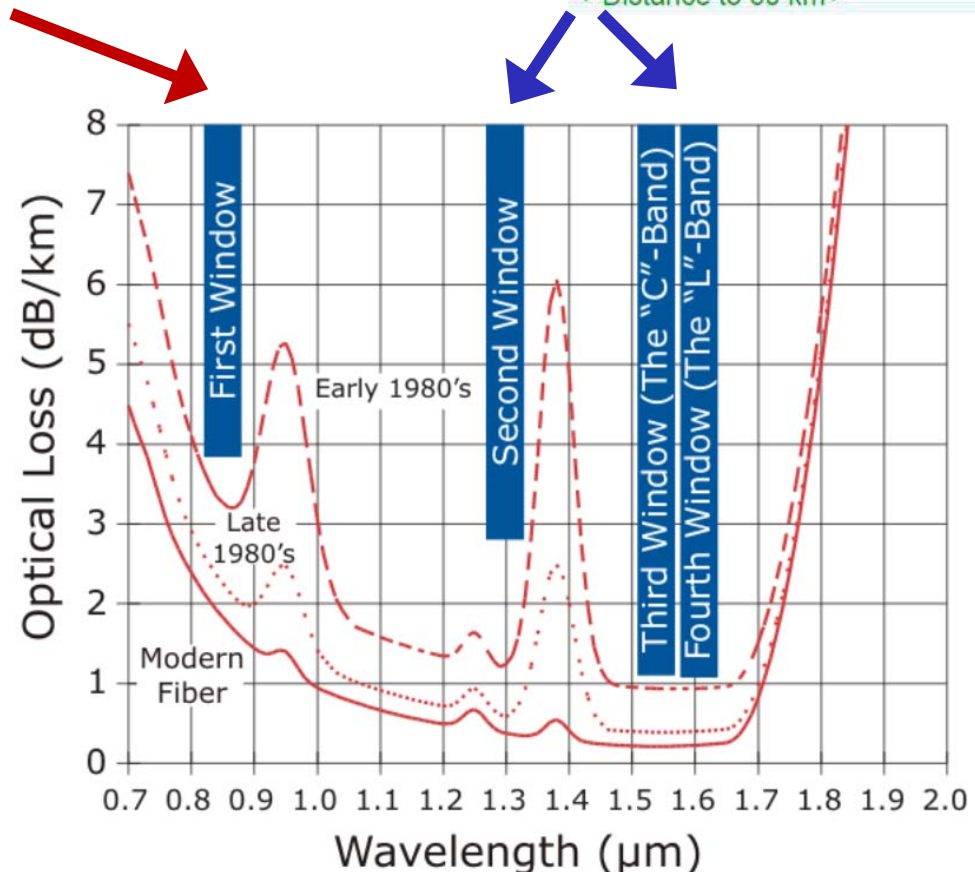


1st generation, ~1975, 0.8 μm
fiber-MM, Laser GaAs

2nd generation, ~1980, 1.3 μm ,
fiber MM SM, InGaAsP FP-laser

3rd generation, ~1985, 1.55 μm ,
fiber SM InGaAsP DFB-laser

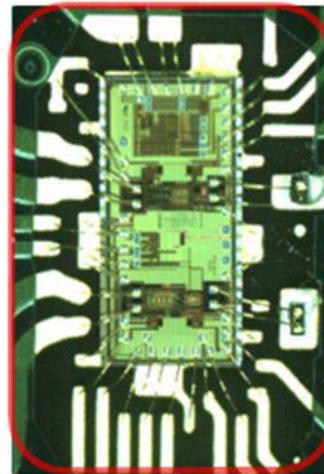
4th generation, 1996, 1.55 μm WDM



Commercial Chip-on-Board

- Light Peak USB 3 transceiver
10 Gbps for consumer electronics
- Lens/Prism :
precision PEI molding

Optical IC

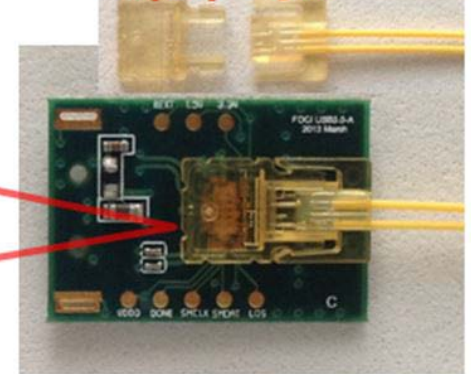


TSMC 90nm process
VIALabs USB 3.0 V0510

(FOCI prism)



Top Cap Pigtail



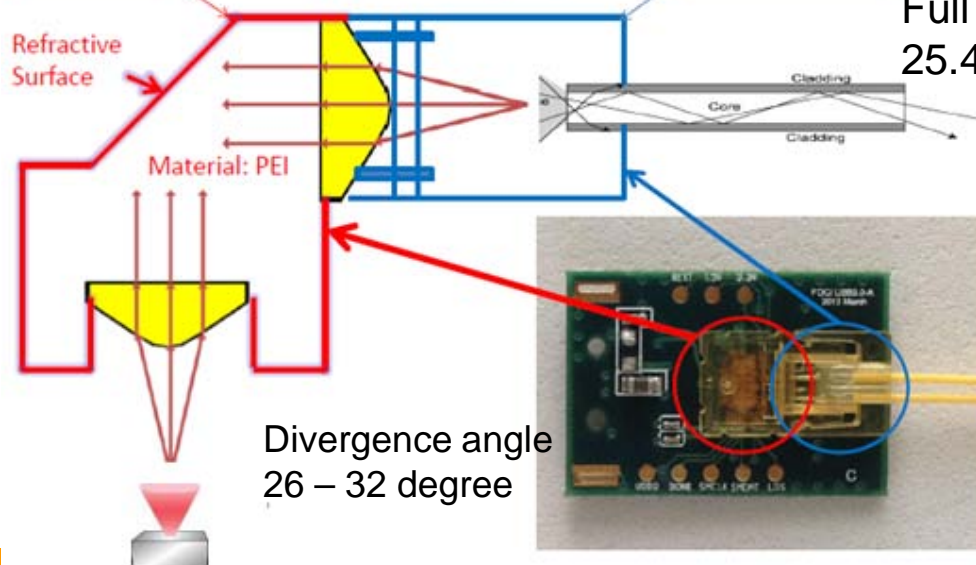
PIN

VCSEL

Prism Receptacle + Plug Ferrule

Spherical-aberration free
Plano-Convex
Hyperbolic Lens

Full acceptance angle
25.4 degree

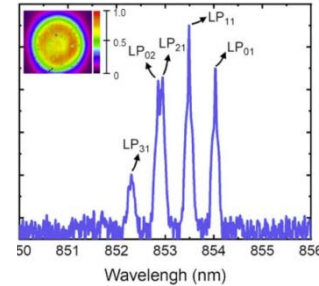
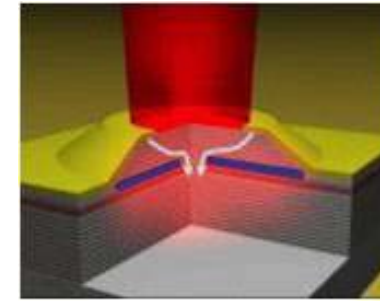
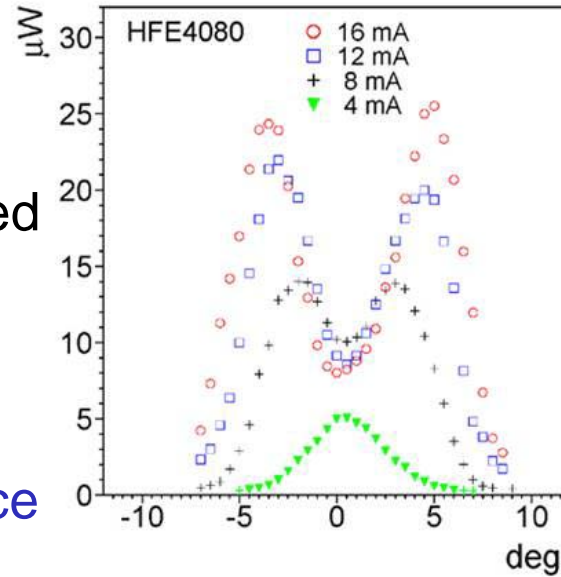


VCSELS aperture
from t Ø 5 to 20 µm

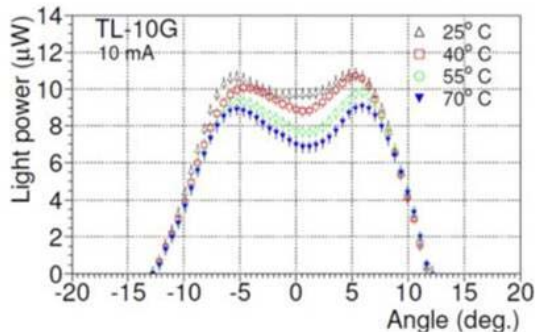
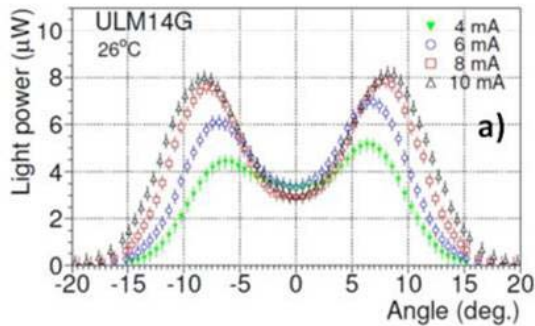
Divergence angle
26 – 32 degree

Light Coupling efficiency

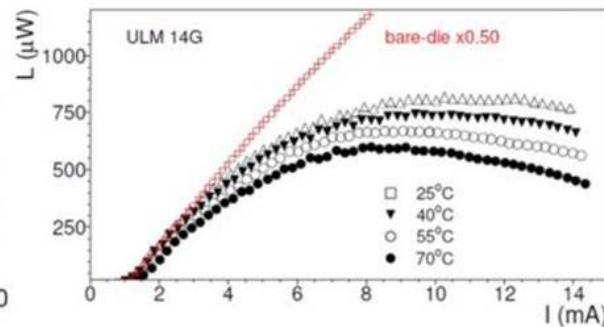
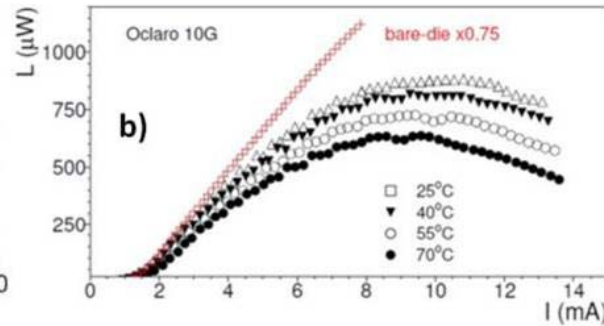
- **VCSEL far-field distribution**
at low current, 0th mode is centralized
higher modes pop-up in outer-rings
wider angles
- **Coupling to Lens**
loss to reflection, angular acceptance



Far-field angle vs I, T



L-I, FOCI lens coupled



VCSEL+Lens in Oven

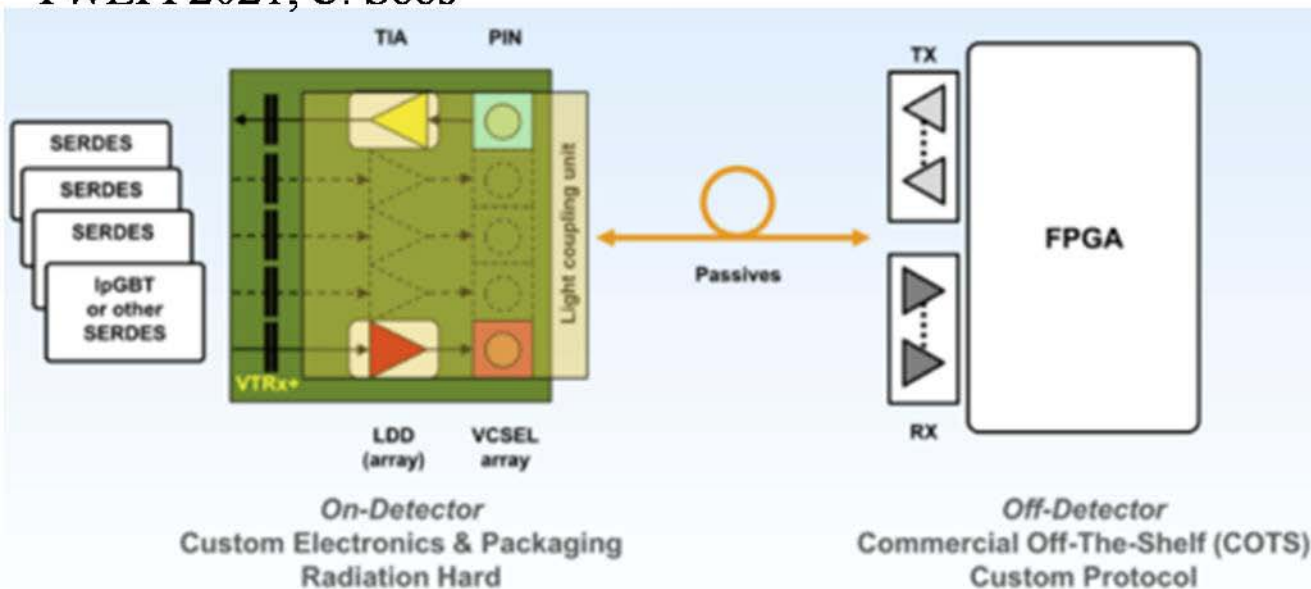


The CERN Phase-II VTRx+ (FOCI 上説)

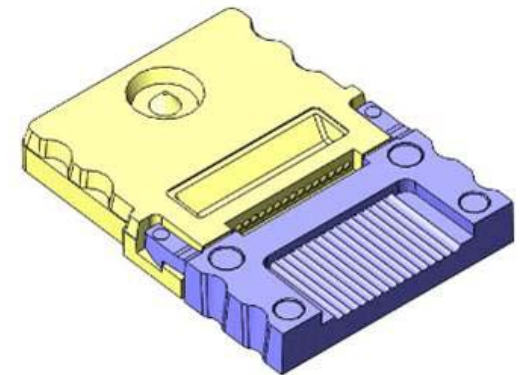
- CERN Versatile Link+ group → one module for all
- 10x20 mm² height 2.5mm, 4.5mm
- 4TX+1RX, 10Gbps TX, 2.56 Gbps RX
- VCSEL array laser driver LQD, TSMC 65nm
- Optical Receiver GBTIA TSMC 65nm
- production 65K pcs
- Lens is the TW Orange-tek



TWEPP2021, C. Soos

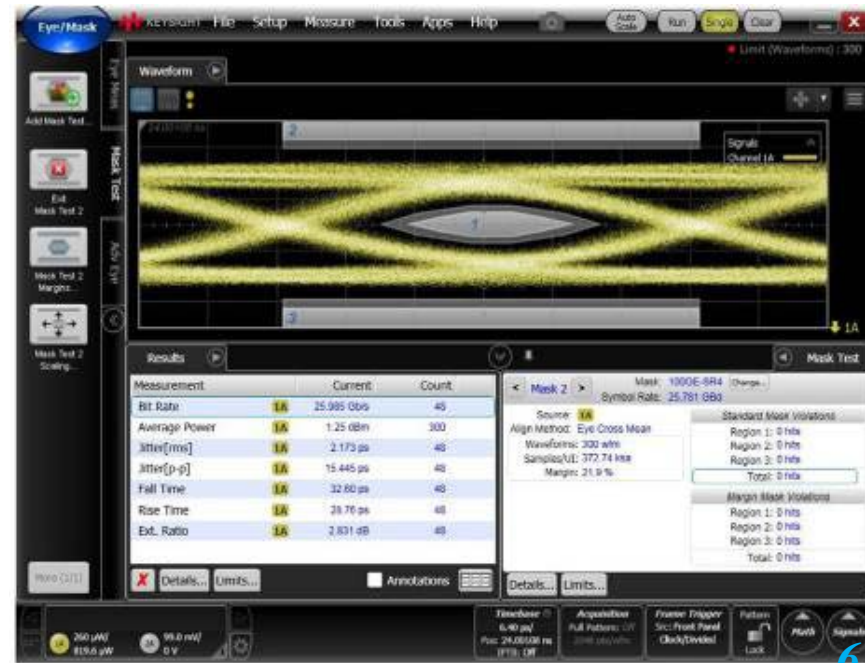
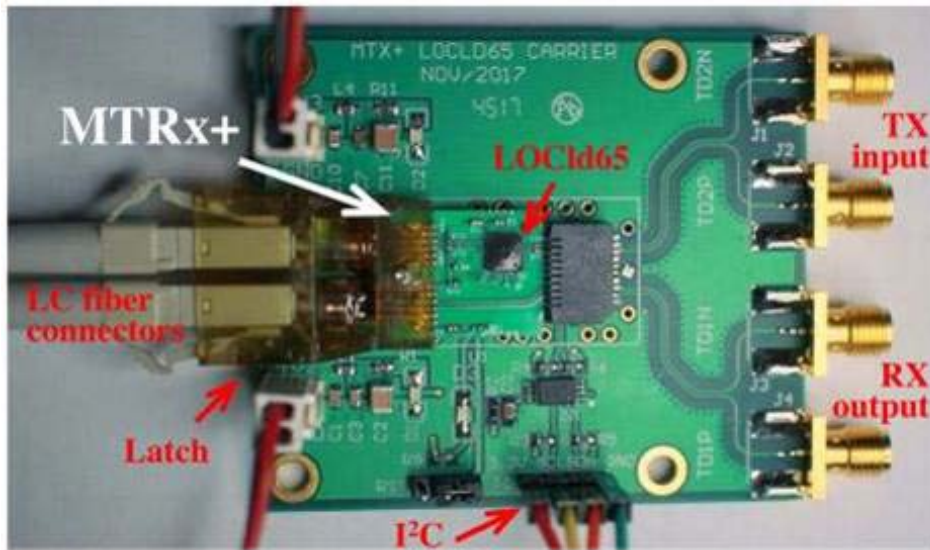
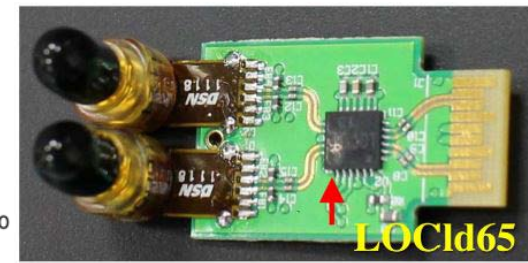
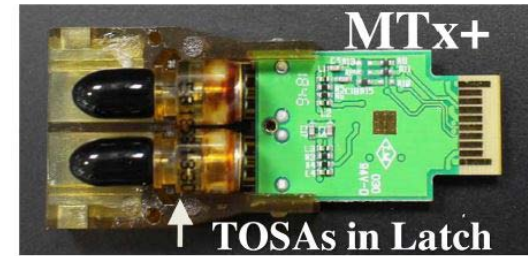
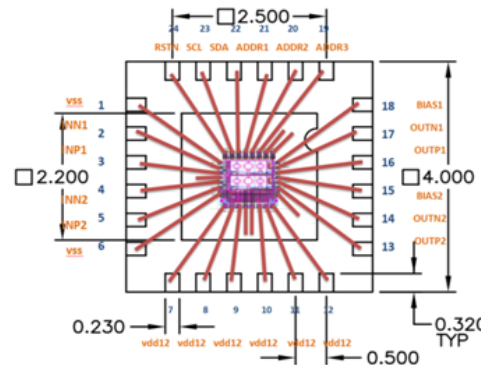
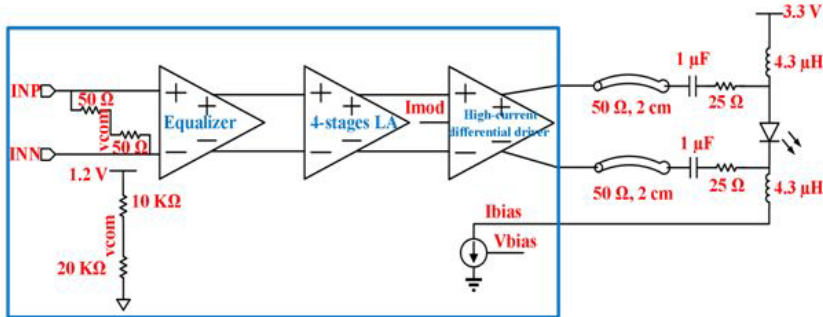


Orange-tek
OT-12, OT-13



AS+SMU+前鼎(APAC) : 25 Gbps Transmitter

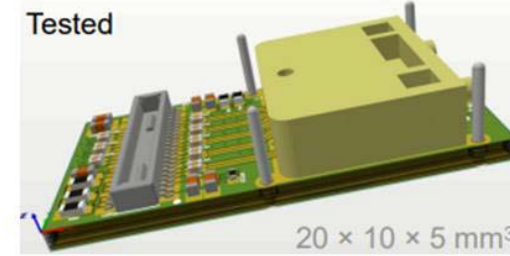
- 25 Gbps components, PCB megtron, connectors
- Driver, LOCLd65, TSMC 65nm



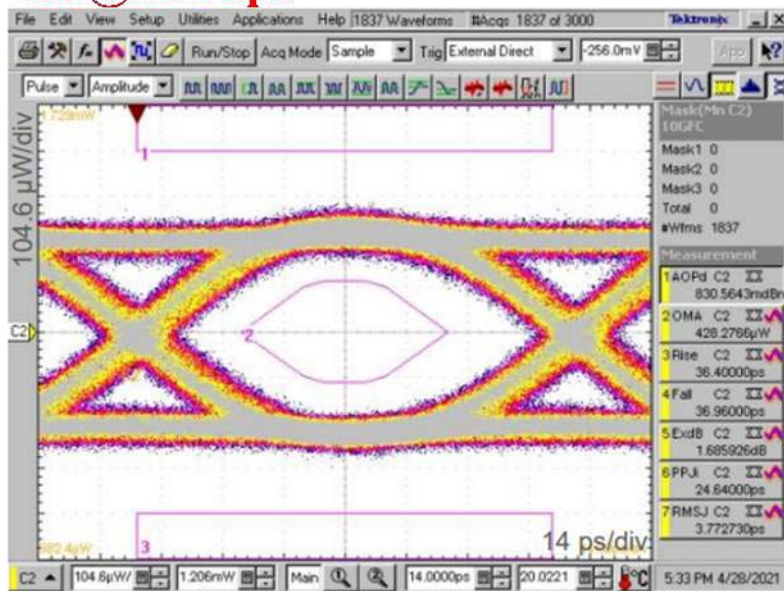
AS+SMU+前鼎 QTRx Transceiver

- 4TX+4RX, tested @ 10G, will do 25 Gbps
- VCSEL, PD, PCB all 25 Gbps qualified
- Driver, QLDD, QTIA, TSMC 65nm

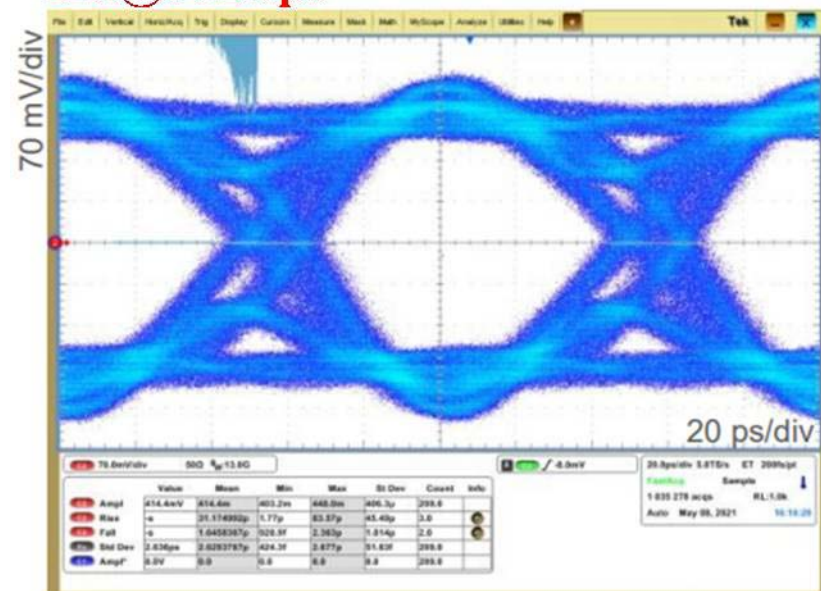
QTRx	QLDD	QTIA	
Data rate	10 Gbps	2.56 Gbps	10 Gbps
Power supply	1.2 V and 2.5 V		
Sensitivity (BER = 1E-12)	80 mV	-17 dBm	-8 dBm
Rise /fall time	37 ps	40 ps	50 ps
Total jitter (BER = 1E-12)	-	38.5 ps	52.4 ps
Power consumption /ch	124 mW	120 mW with CP	



TX@10Gbps



RX@10Gbps



Radiation damage to PEI, epoxy Lens

- The light coupler cap

Spherical-aberration free Plano-Convex Hyperbolic Lens
Material: PEI (polyetherimide), as for the TOSA/ROSA tip
optical quality surface

- Deterioration by Total-Ionizing-Dose

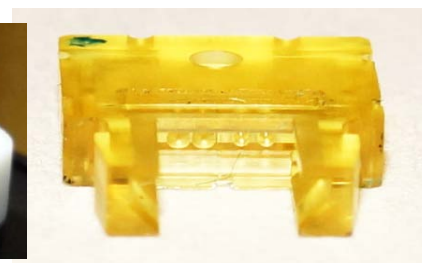
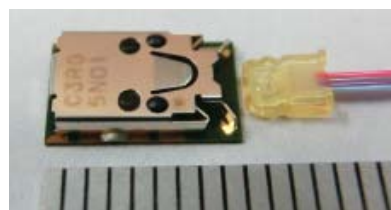
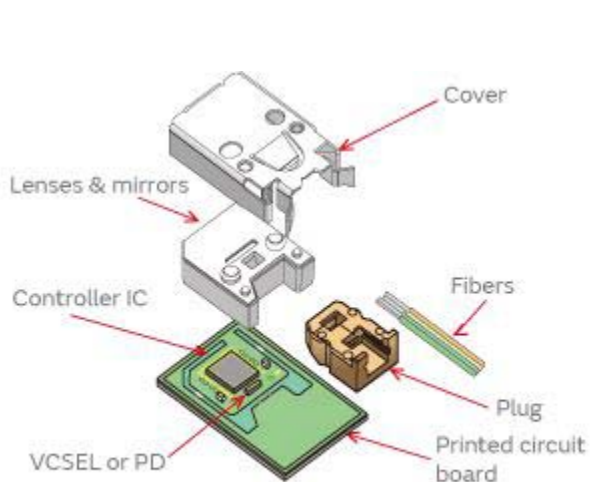
Irradiated with Co^{60} Gamma ray
at INER Taiwan

flux: 3.5 kGy/hr, total: 117 kGy

→ NO LOSS !!

for light transmission

within the 2% systematic error



muRata epoxy lenses

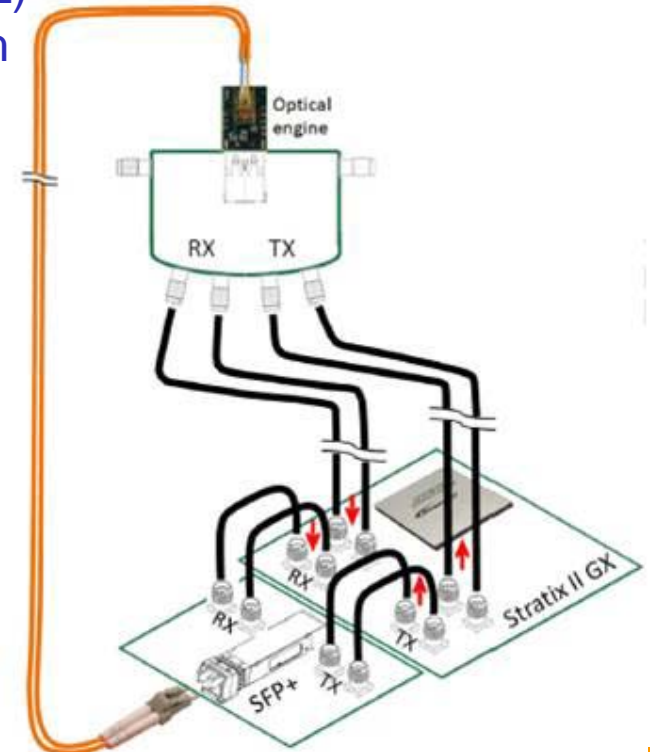
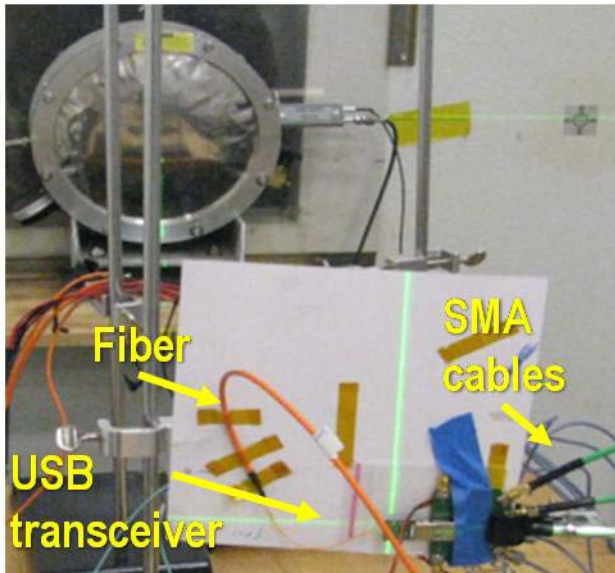
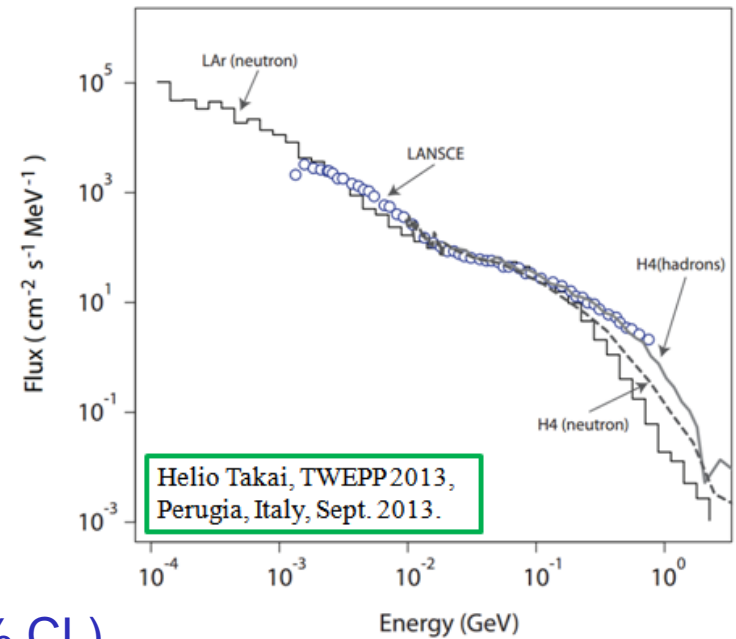
LANSCCE neutron test

- Beam profile similar to ATLAS
- **USB transceiver in Bit-Err-Rate**
Straitix II GX, PRBS 2⁷-1 bit pattern
TX path, RX path tested separately

neutron flux 2.9×10^5 n/cm²s
over 1.5 days to 3.8×10^{10} n/cm²

TX: 0 error, upper limit 1.0×10^{-10} cm²/ch (95% CL)

RX: 11 errors SEE cross section 2.9×10^{-10} cm²/ch



Non-Ionizing Energy Loss to VCSEL, Optical IC

– Proton Irradiation

INER 30 MeV proton cyclotron
flux of 2×10^{12} p/cm²s, to a total 1.2×10^{14}
equivalent to 4.8×10^{14} n(1MeV)/cm²s

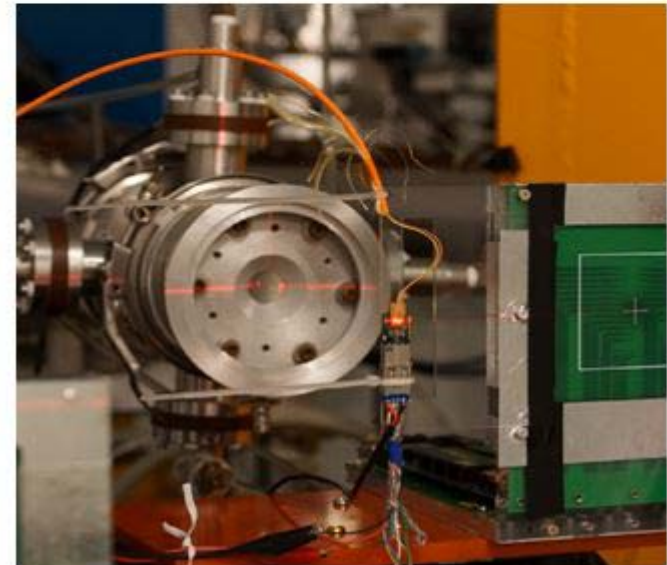
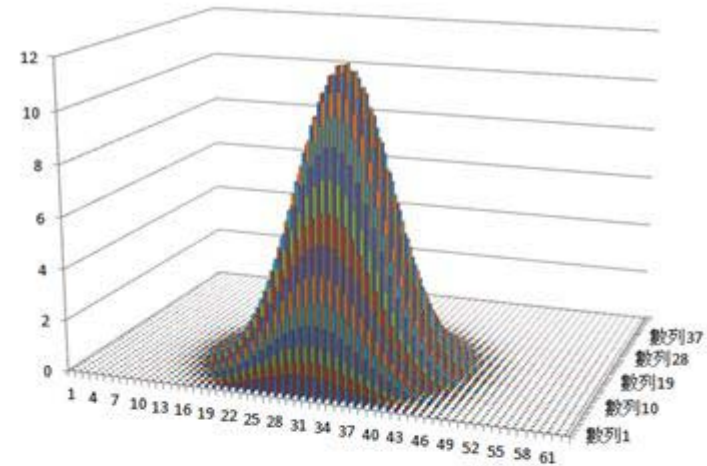
– Beam profile

Strip and pad chambers for beam profile
strip pitch 1 mm

– Irradiation measurement

FOCI module DC biased
no signal input,
VCSEL online monitored
for mid-level DC light

- VCSEL light degradation
- Optical IC function



VCSEL rad-hard degradation, annealing

Indiana IUCF Cyclotron 200 MeV proton

VCSEL light degradation → linear to fluence

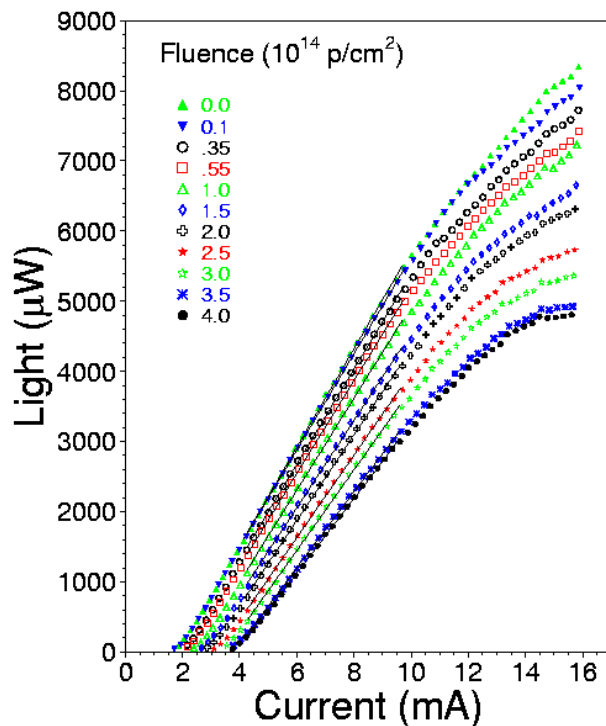
rad-hard fiber connected to readout, independent of flux rate

Fast annealing by charge injection

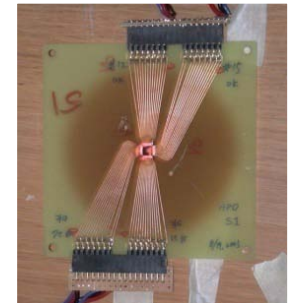
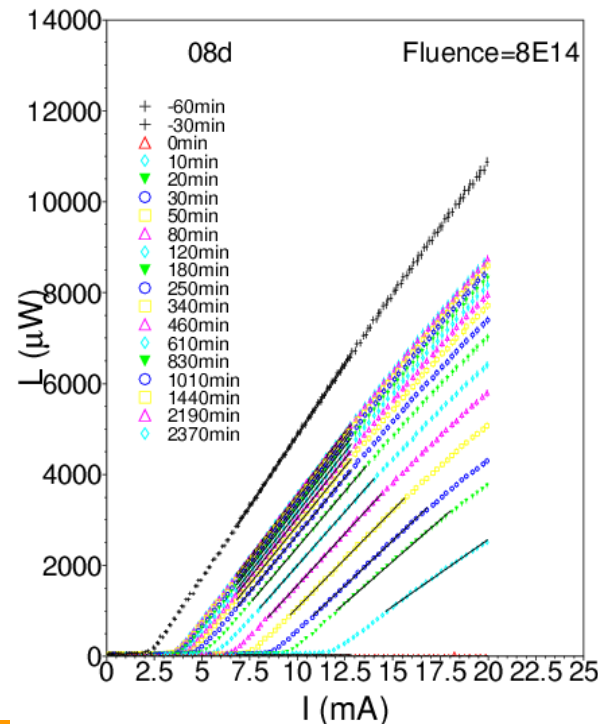
at operation current (10 nA) applied

1st generation Oxide VCSEL
1 Gbps Truelight

L-I of VCSEL (oxide)
vs. **online** Fluence



L-I of VCSEL (oxide)
vs. **Annealing** time



NIEL to GaAs diodes

850 nm VCSELs, 1 Gbps

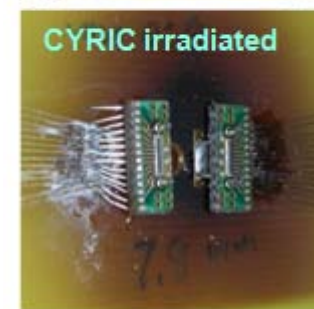
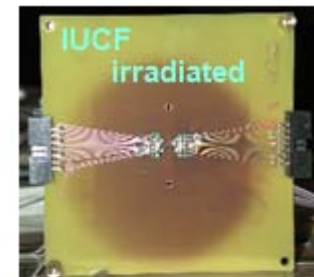
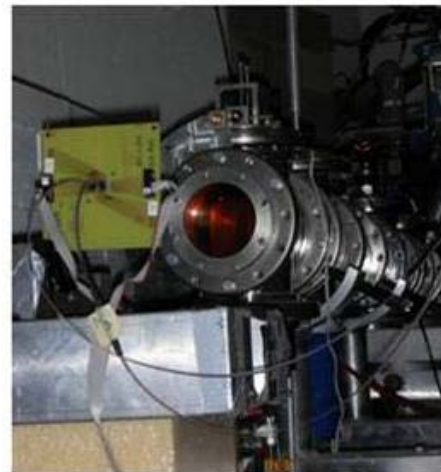
NIEL damage

→ light degradation linear to fluence

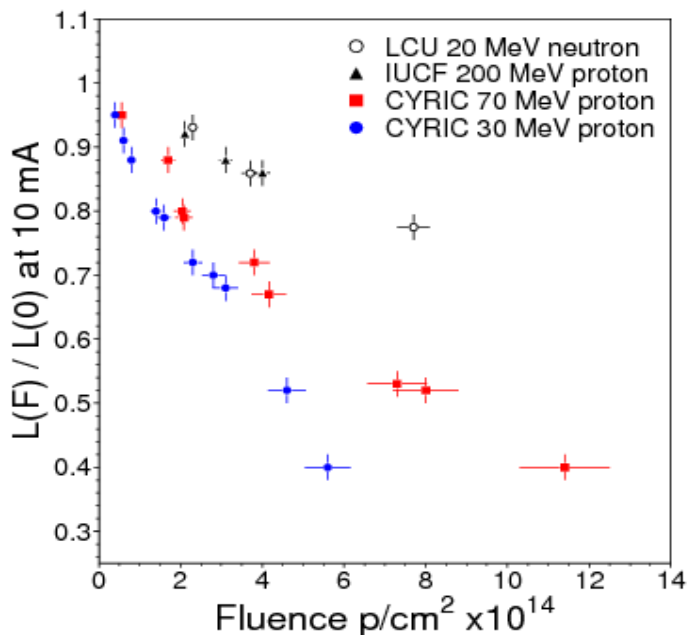
Higher proton momentum

→ less damage to GaAs components
(contrary to theoretical calculations)

IUCF beam area

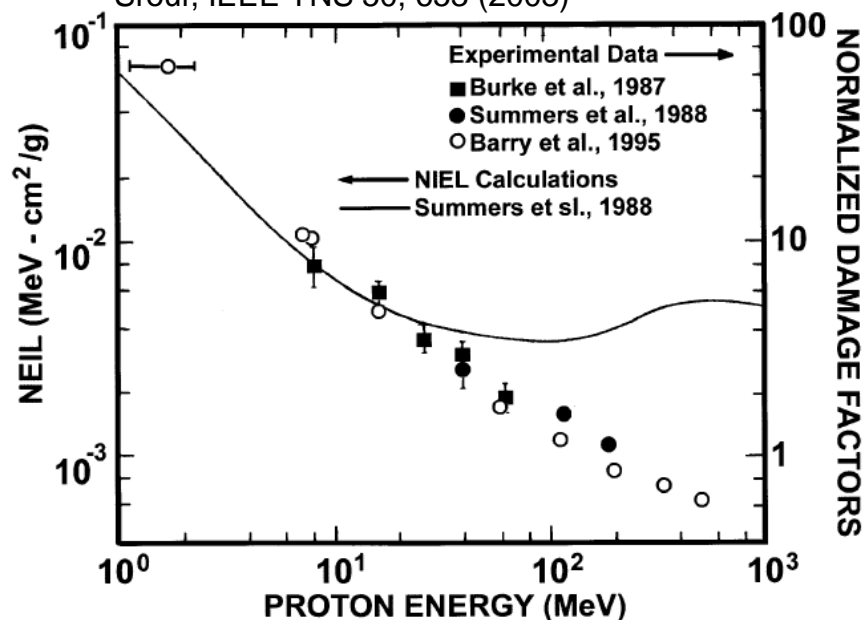


VCSEL (GaAs) light degradation



GaAs solar cell measurements

Srouf, IEEE TNS 50, 653 (2003)



PIN proton damage

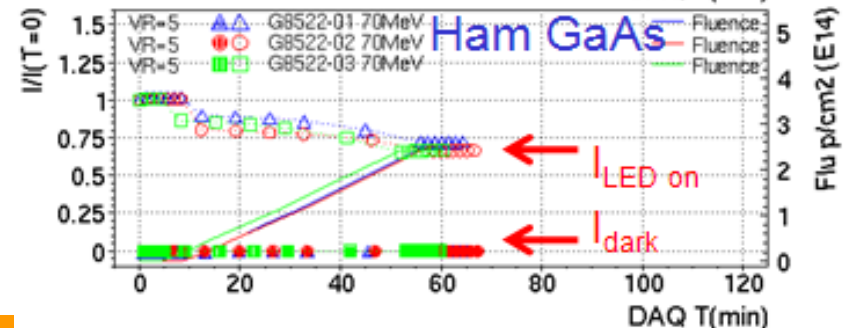
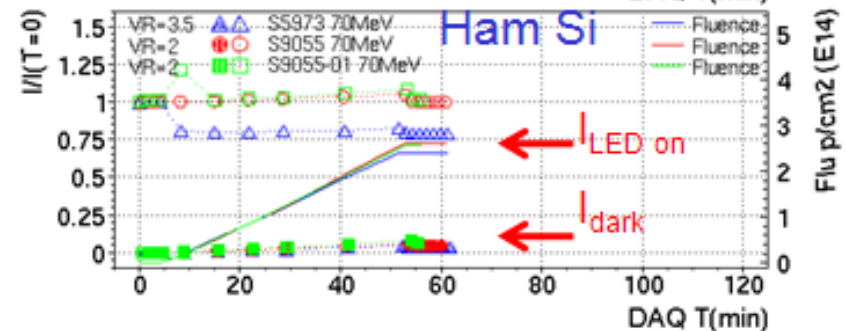
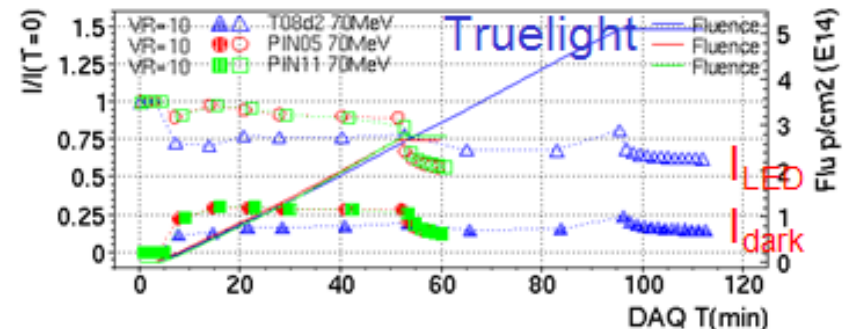


Degradation of responsivity (I/L) proton 2E14

	V_R Vol	f_c GHz	diam. μm	I/L A/W	30 MeV		70 MeV	
					I/L ratio	Dark nA	I/L ratio	Dark nA
Truelight	-10		100	0.55	45%	70	45%	50
S9055	-2	1.5	200	0.32	100%	40	100%	20
S9055-01	-2	2.0	100	0.20	100%	15	100%	10
S5973	-3	1.5	400	0.53	70%	100	80%	50
G8500-01	-5	3.0	40	0.11	45%	0	80%	0
G8500-02	-5	1.9	80	0.25	40%	0	72%	0
G8500-03	-5	1.5	120	0.40	35%	0	72%	0

- PIN rad-hardness
diameter, thickness →
A/W, speed & rad-hard
- Proton energy dependence
Si PIN : compatible with
30 MeV and 70 MeV protons
GaAs PIN : twice damage by 30 MeV
than 70 MeV protons

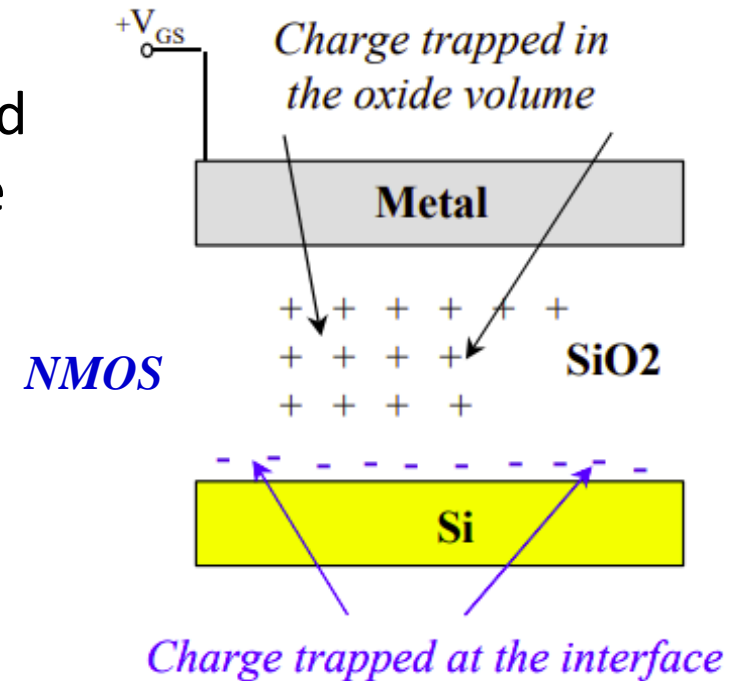
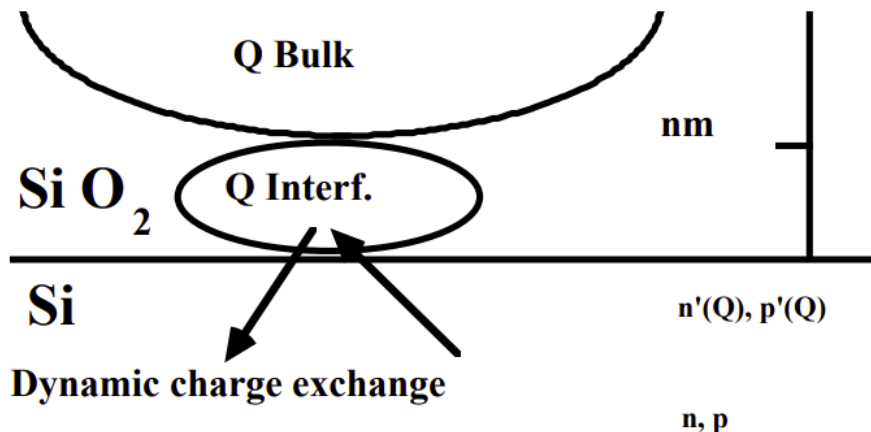
70 MeV proton



TID effects on CMOS

Total Ionizing Dose (TID) induces charge-trapping at **Si-SiO₂ interface**
Dependence : total dose, dose rate, annealing

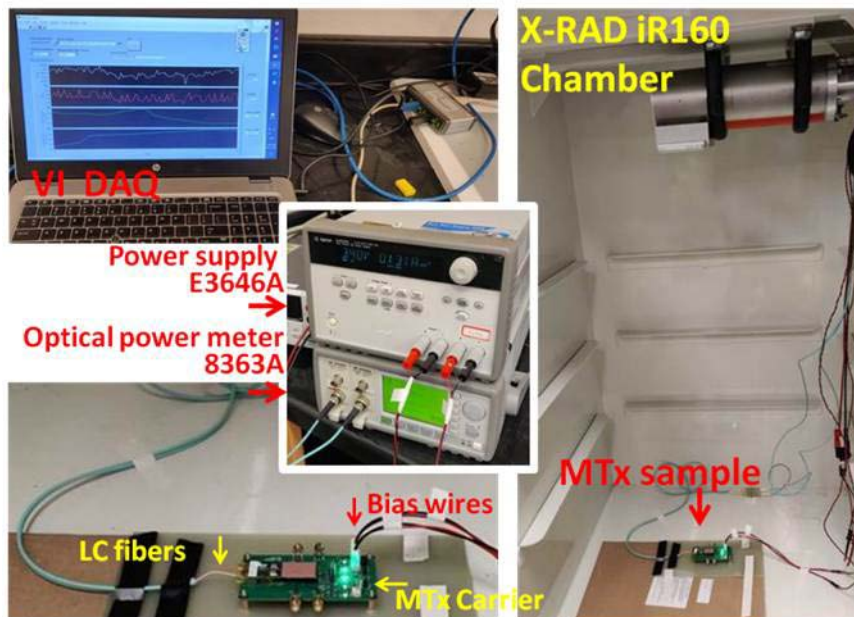
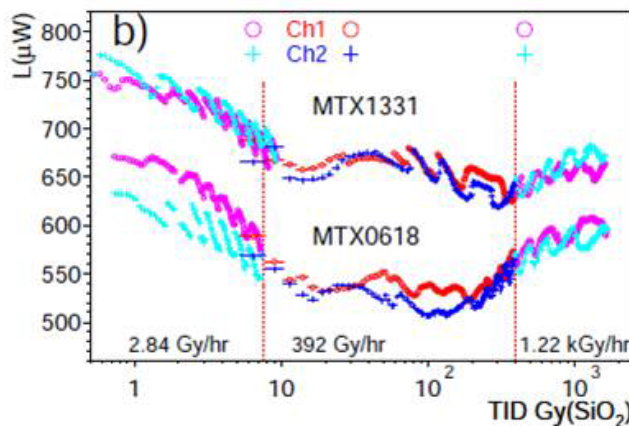
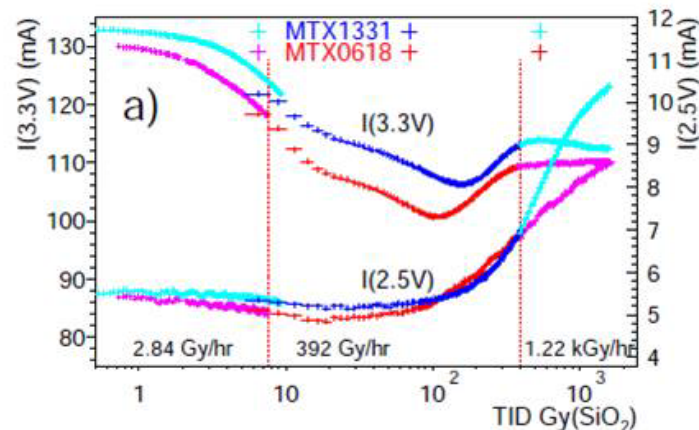
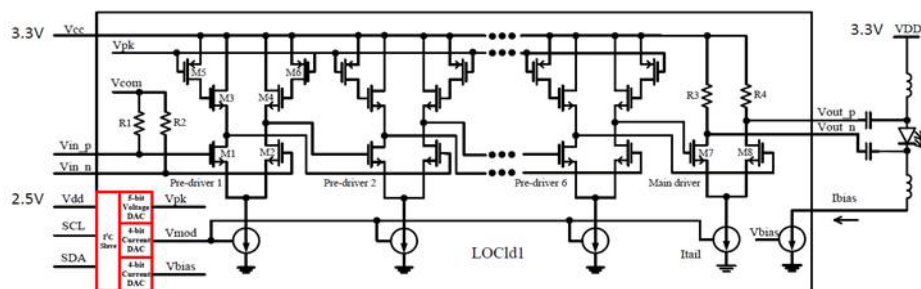
- new interface states formed.
- interface state density vs. energy changed
- interface state density changes with time
- construction after irradiation
- static and dynamic electrical response of the Si-SiO₂ altered



Threshold voltage degradation
as a function of the total Dose

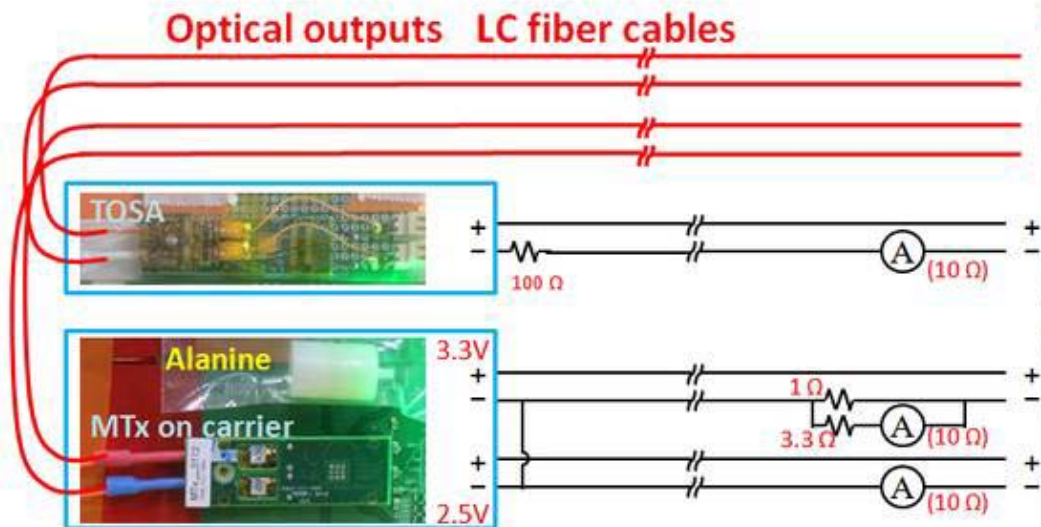
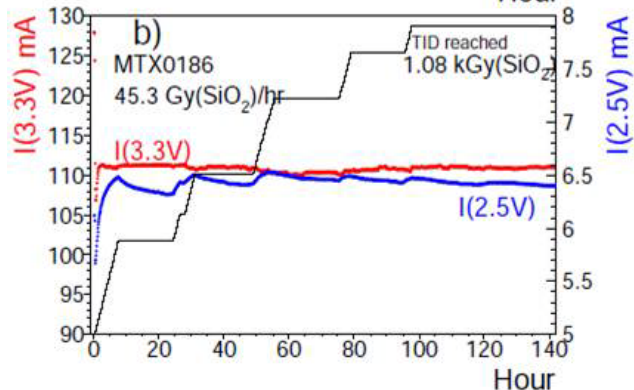
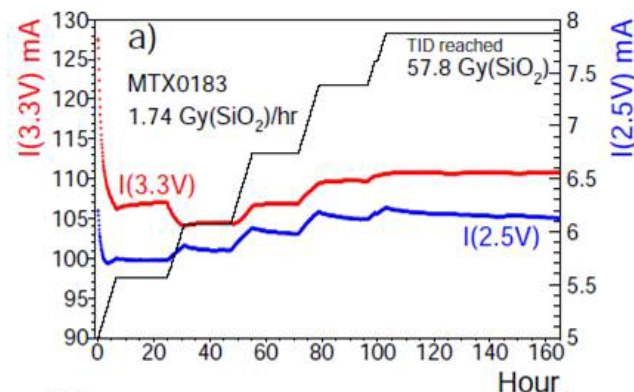
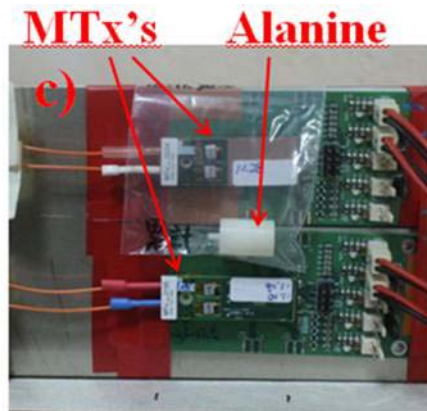
X-ray TID on MTX LOCI_d of ATLAS LAr

X-ray, 3 dose-rates in 280 min to 1.62 kGy(SiO₂)
 LOCI_d laser driver shows degradation



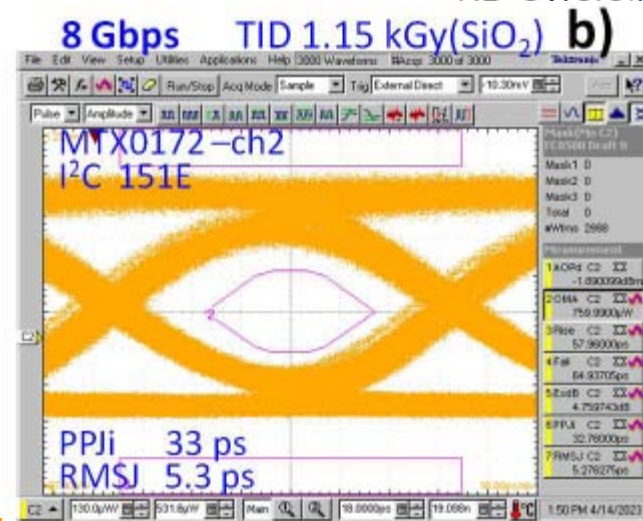
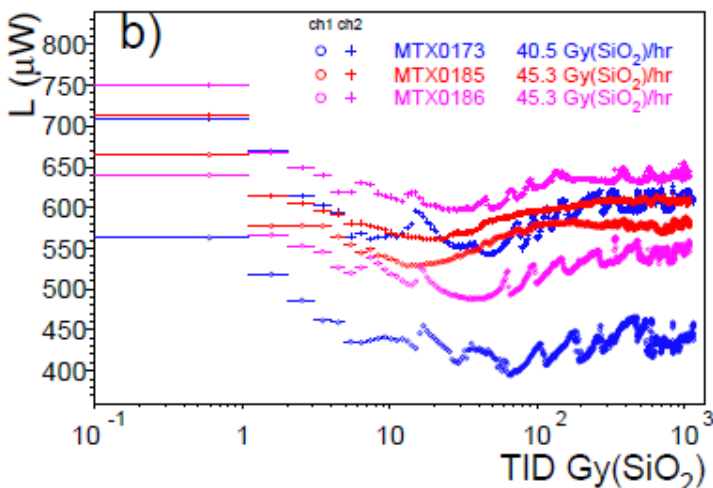
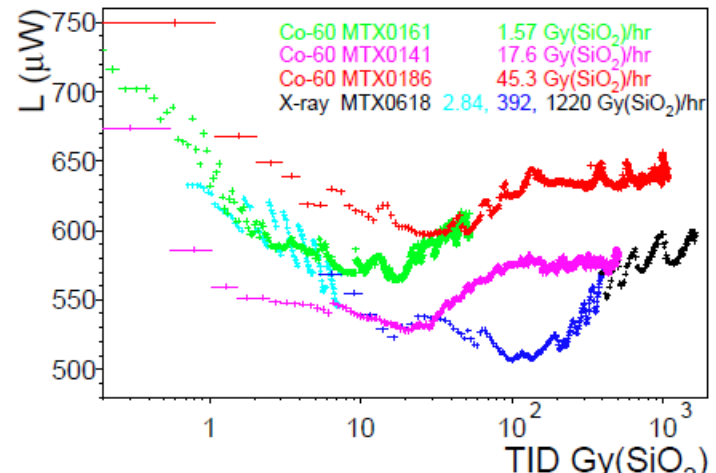
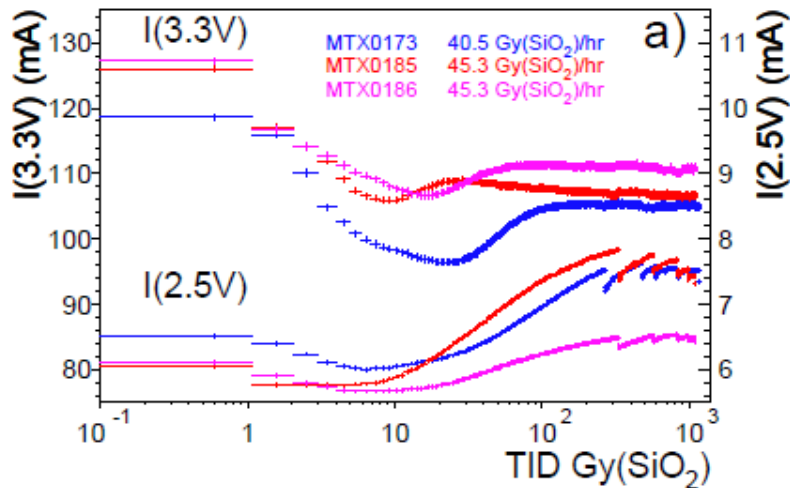
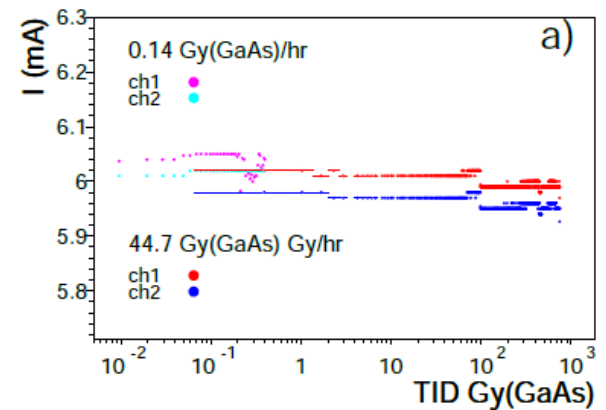
Co-60 TID on MTX LOCIId

Co-60 varying dose-rates 0.14 to 45 Gy/hr
 Irradiation in daytime, annealing overnight
 Dose calibration using Alanine



Co-60 TID on MTX LOCl d

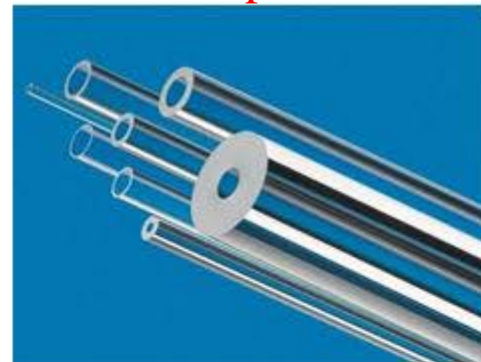
Co-60 lower rate to X-ray, mio
VCSEL not effected by TID
CMOS current drops ~ 10-100 Gy(SiO₂)



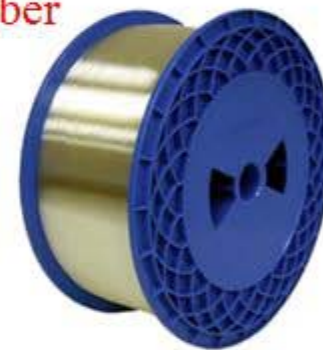
Optical fiber making

PCVD plasma chemical vapor Deposition
MCVD modified chemical vapor deposition
OVD outside vapor deposition
VAD vapor axial deposition

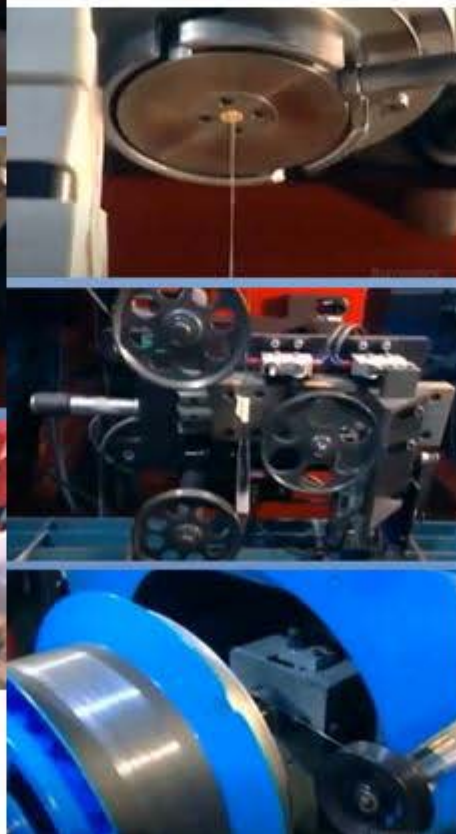
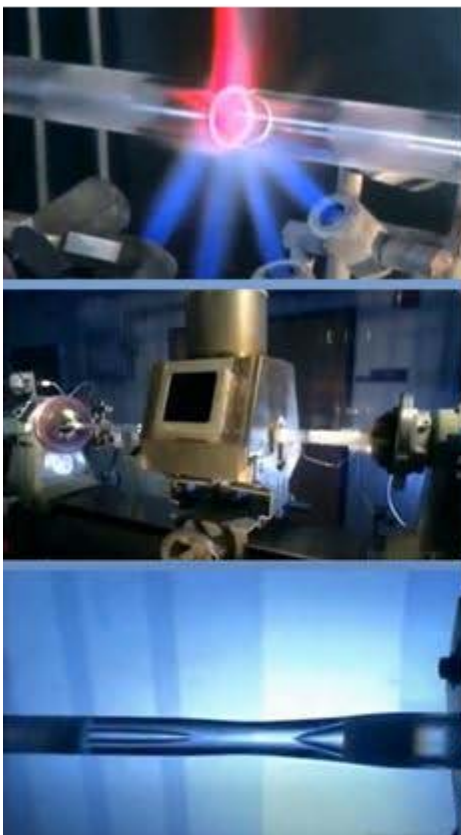
Fused Silica Tubes,
pure SiO_2
for Fiber Optics,



Bare Fiber
Reel



Fiber Cable



Looking for testing 武汉 YOFC
长飞光纤 Ge-doped, Rad-hard fibers

Co-60 irradiation facility

Bare fiber sample in bag, with SC connectors in water bath, const °C



Ge-doped MM fiber, Co-60 test

Fiber Radiation Induced Attenuation (RIA)

$$\text{RIA} = (\text{IL}(0) - \text{IL}(t)) / \text{Length}$$

$$\text{IL}(\text{dB}) = 10 \times \log_{10} (P_T / P_R)$$

IL insertion loss

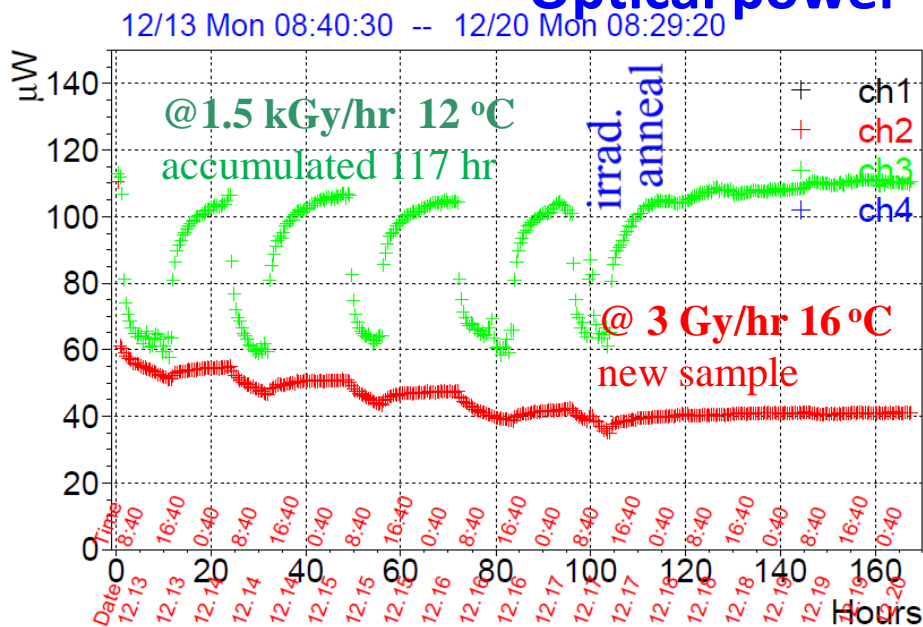
P_T transmitter, P_R received

Dependences : Dose rate, Temperature

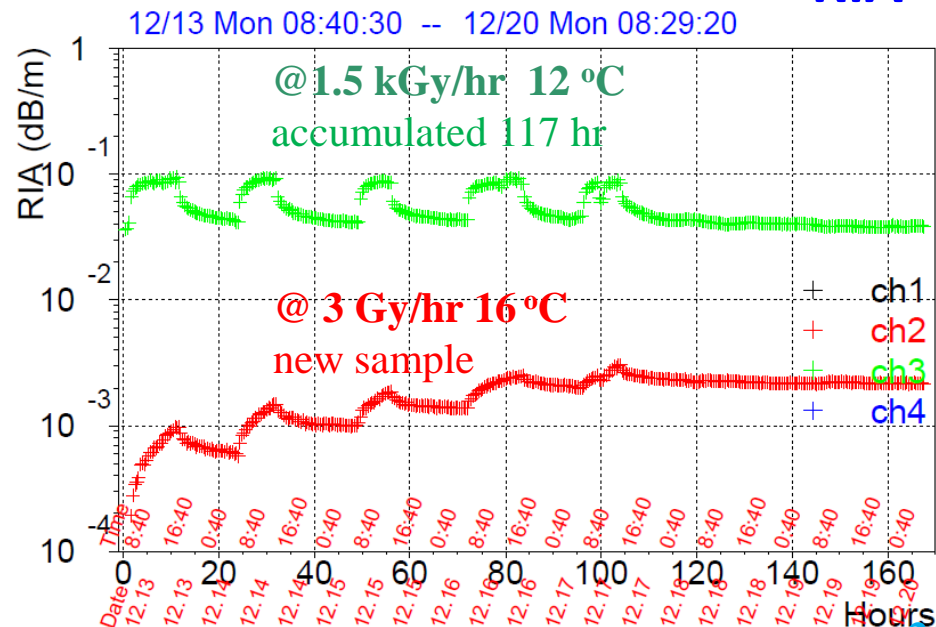
Fibers tested at Dose rate 1.5kGy/hr

Irrad ~8hr daytime, anneal overnight, over 1 week

Optical power



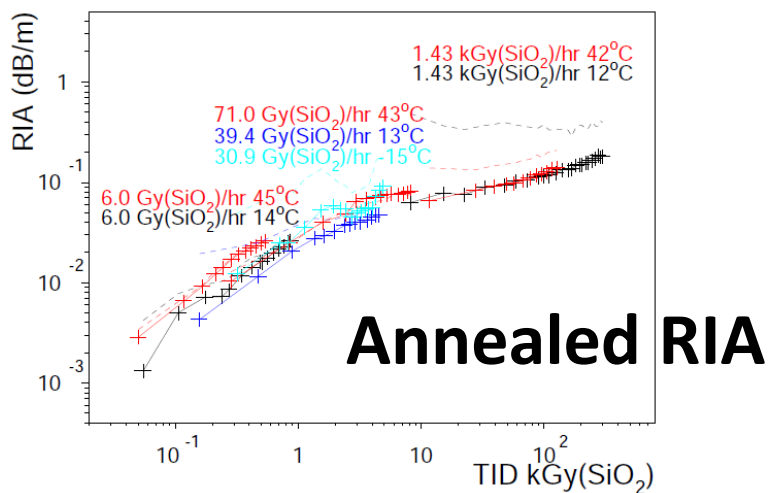
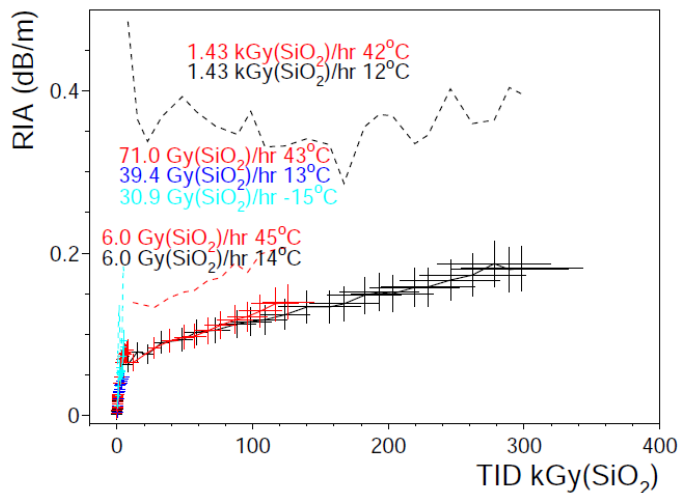
RIA



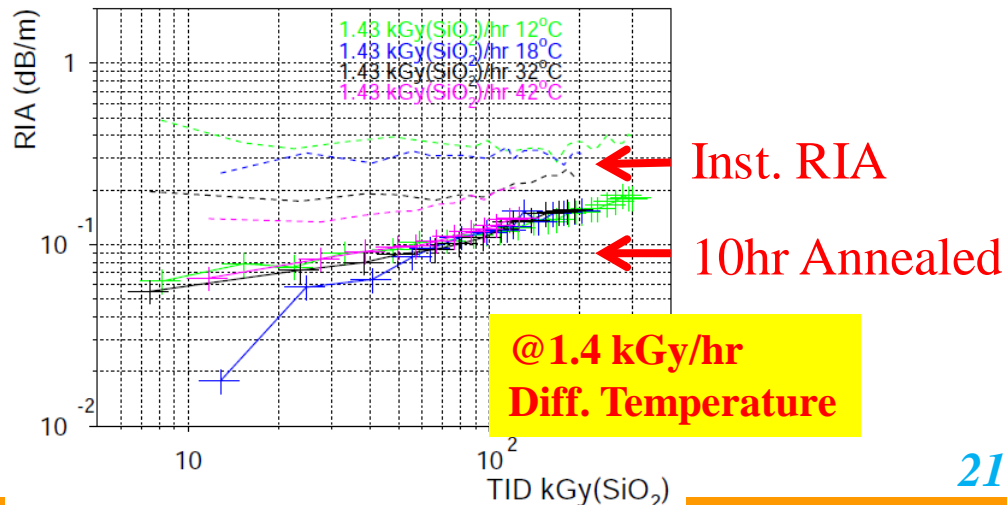
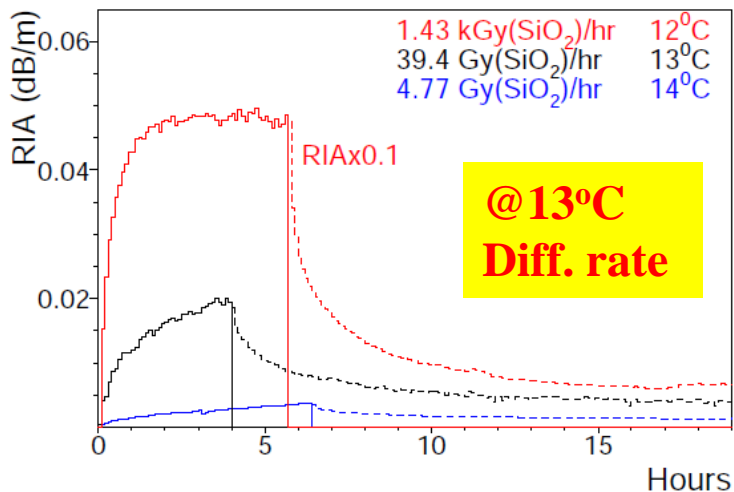
Ge-doped MM fiber (POFC 0.2 dB/m 300 kGy)

Dashed lines: Instant RIA, at daily max dose

Points: RIA after 10 hr annealing



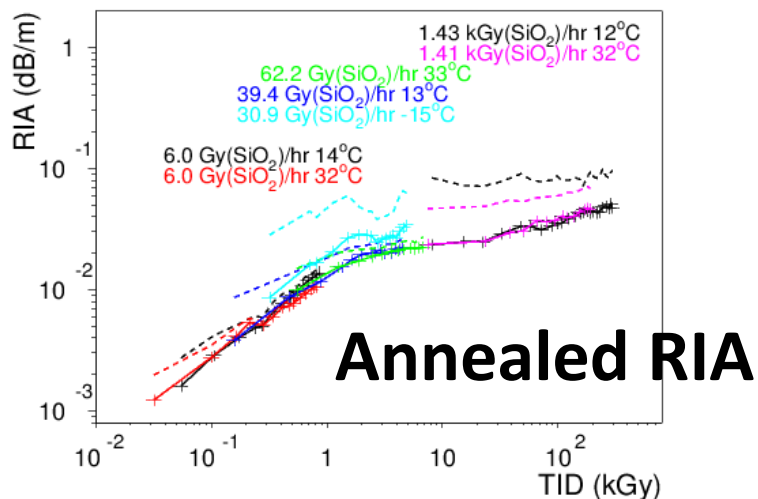
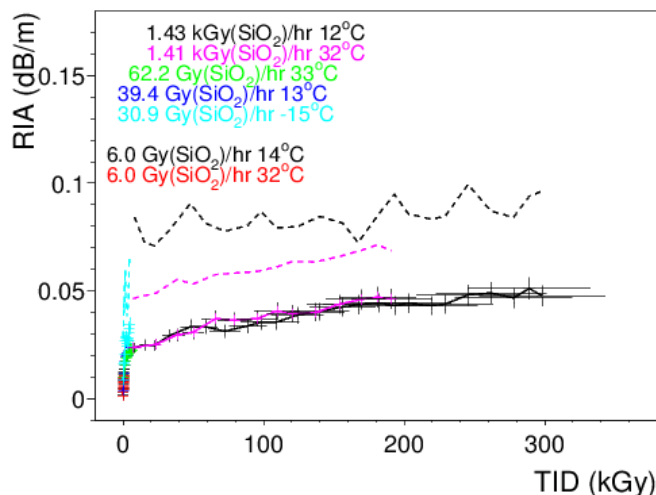
- **Dose Rate** : higher rate → higher instant RIA
- **Temperature** : lower T → higher instant RIA



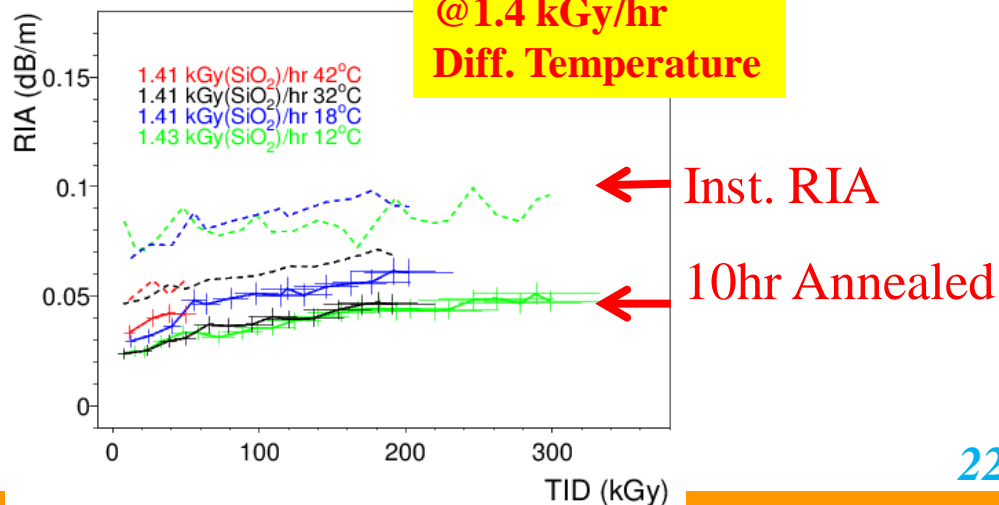
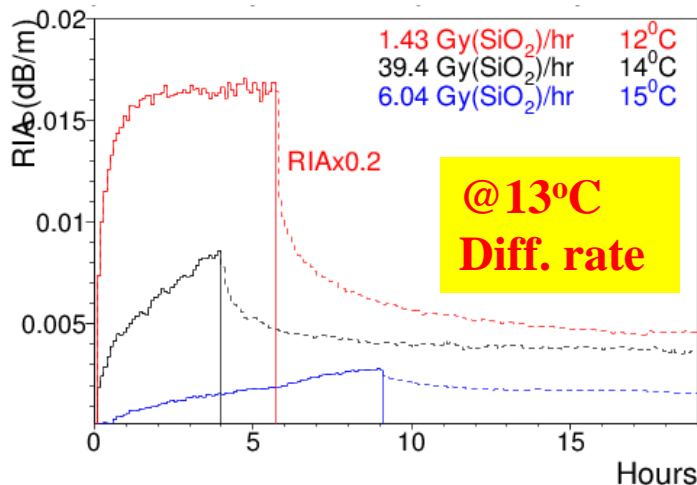
Ge-doped MM fiber (Co. 0.04 dB/m 300 kGy)

Dashed lines: Instant RIA, at daily max dose

Points: RIA after 10 hr annealing



- **Dose Rate** : higher rate \rightarrow higher instant RIA
- **Temperature** : lower T \rightarrow higher instant RIA



Summary

- **Opto COB assembly is mature >10 Gbps**

PCB: 10 GHz FR4, 25 GHz, Megtron,

Electric connectors: SFP, QSFP, Hirose, Firefly

Optical coupling: LC, MT, mini-pigtails

- **Radiation hardness**

Ge-doped MM fiber, good to 0.04 dB/m 300 kGy

NIEL on VCSEL, PD

TID, SEE on ASIC